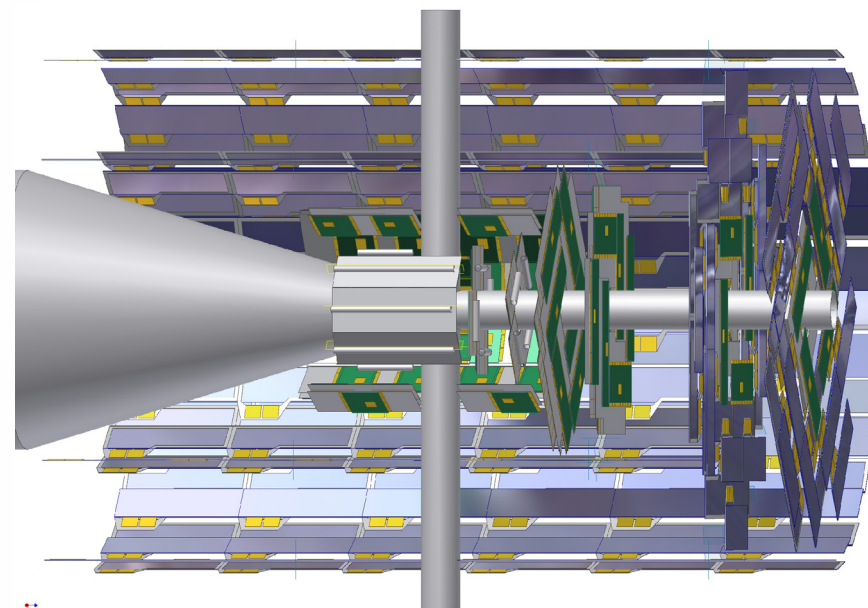
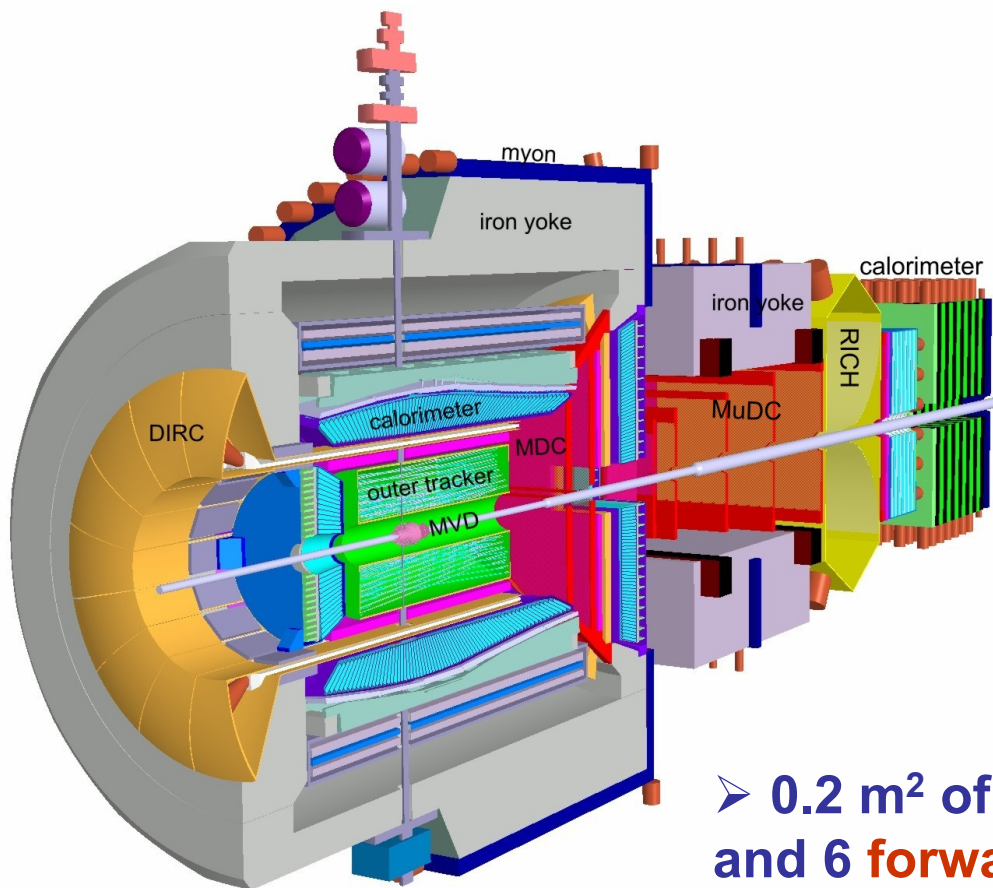


Front-end electronics for the PANDA pixel detectors: a custom solution in 0.13 μm ?

A. Rivetti – INFN – Sezione di Torino

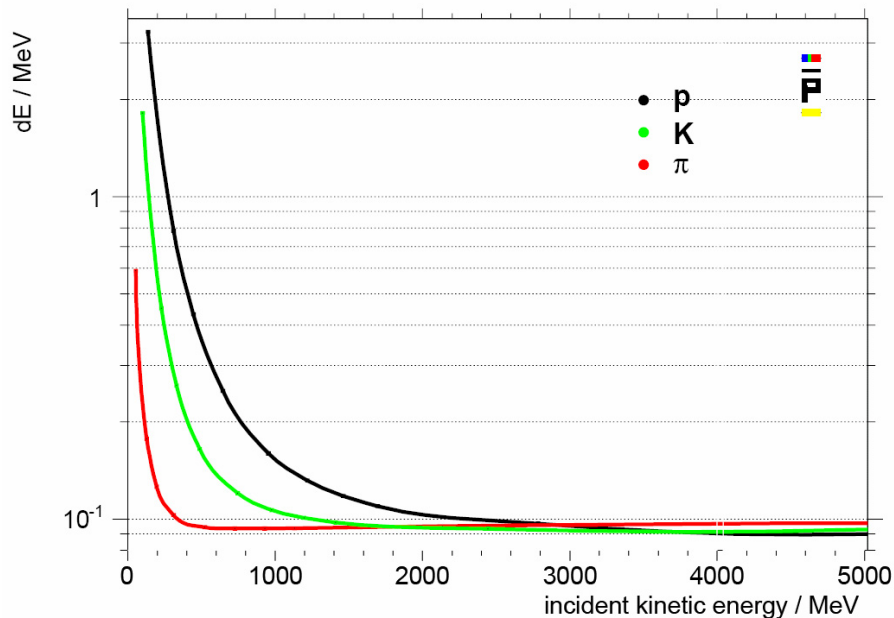
- The PANDA MVD: overview and requirements for pixels.
- Design options: “off the shelf” versus custom.
- Architecture of the custom solution: first considerations.
- Technology selection.
- R&D timeline.
- Summary.



- 0.2 m² of silicon detectors: 4 **barrels** layers and 6 **forward disks**.
- 2 barrels and all disks equipped with **hybrid pixel sensors**.

- Annihilation rate: $10^7/\text{sec}$.
- Low-momentum particles:
 - Low material budget
 - High dynamic range
- Analogue read-out for dE/dx PID ($<700 \text{ GeV}/c$).
- Space resolution: better than $100 \mu\text{m}$.
- Radiation tolerance ($10^{14} n_{\text{eq}}/\text{cm}^2$).
- Triggerless DAQ.

➤ Assuming a 200 μm thick detector we can estimate:



- Minimum input charge: 7,000 electrons.
- Maximum input charge: 250,000 electrons.
- Full scale analogue resolution: 9.2 bits.
- Good overdrive recovery

Warning: amplitude distribution not taken into account!

Energy loss in 400 μm silicon as a function of kinetic energy (from the PANDA TPR).

- Recent simulations done in Jülich* about resolution and hit rate.
- **Three** different pixel **sizes** were compared:
 - ATLAS (**50** μm x **400** μm \rightarrow resolution: **84** μm (z); **75** μm (r, ϕ))
 - CMS (**150** μm x **100** μm \rightarrow resolution: **55** μm (z); **62** μm (r, ϕ))
 - Custom (**75** μm x **75** μm \rightarrow resolution: **48** μm (z); **52** μm (r, ϕ))
- The goal of a resolution smaller than 100 μm is always achieved. However a square pixel of **100** μm x **100** μm or less would give more **safety margin** and simplify the **mechanics** (with very asymmetric pixels **orientation** have to be **changed** in different layers).
- For the ATLAS chip (8 mm x 7.2 mm) maximum hit rates of **1.54 MHz/chip** and **16 kHz/pixel** have been estimated.

* T. Stockmanns, J. Ritman and A. Sokolov, "The Micro-Vertex-Detector of the PANDA Experiment at FAIR", presented at Pixel05, Bonn September 2005.

- A lot of **developments** have been done by the LHC community, but:
 - **ALICE** chip purely **binary**.
 - **CMS** ROC has a too small **dynamic range** (2 MIPS).
 - **ATLAS** chip **closest** to the required specs.

- However:
 - the ATLAS module **can not** be used in a **triggerless** environment (module controller to be redesigned).
 - **Asymmetric pixels** complicate the **layout** and limit the resolution.
 - Performance at the required **event rate** in triggerless mode must be assessed.

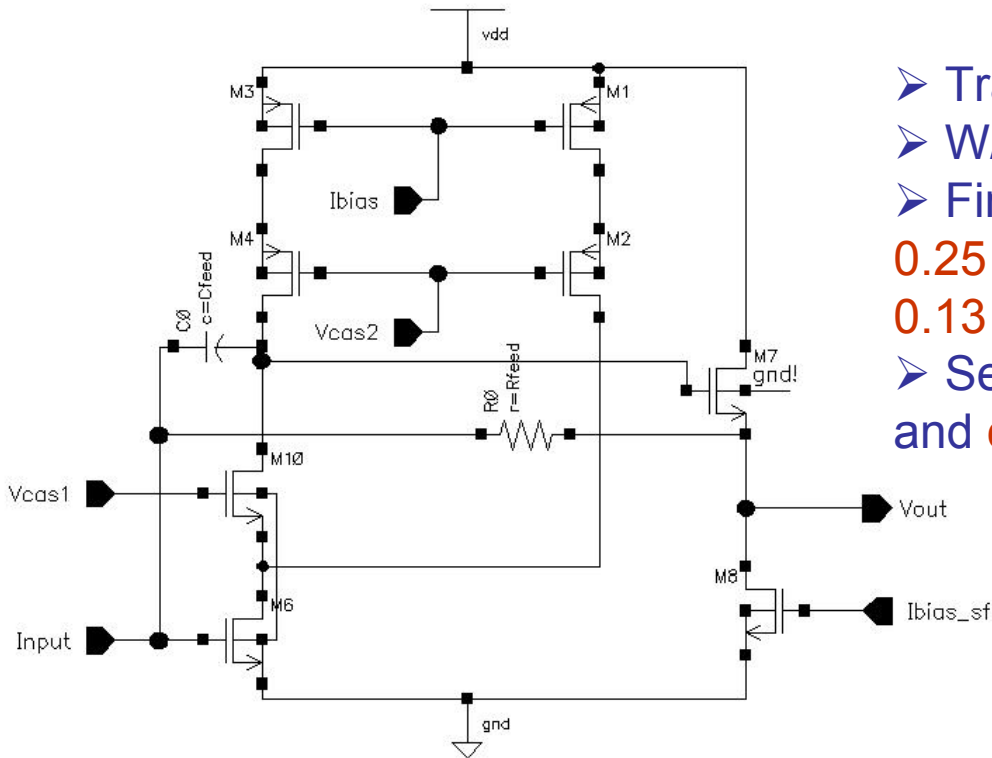
- Room for investigating a **custom** solution.

- Pixel size: 100 μm x 100 μm .
- Chip size: 13 mm x 15 mm.
- Chip active area 13 mm x 13 mm → 16384 pixels
- Data for each event
 - Pixel address (14 bits)
 - Time stamp (8-10 bits)
 - Amplitude information (8 – 10 bits)
 - Parity (1 bit)
 - Chip header (3 bits)
- Total: 38 – 40 bits per chip (80 differential pads).
- In 13 mm about 185 pads are possible, but power distribution on both sides preferable. Pad number can be reduced serializing data transmission at the expense of bandwidth or power consumption.

- Master clock of **50 MHz**.
- Simple **time domain multiplexing** should be adequate.
- **Four** chips multiplexed on **one** bus.
- At **each clock** cycle one of the chips put on the bus either **valid data** (information of **one pixel**) or **dummy data**.
- Bandwidth per chip: **12.5 MHz**.
- Data are reorganized in the controller unit (dummy suppression).
- Output bandwidth: between **1.5 and 2 Gbits/sec**.
- More **flexible** architectures under considerations.

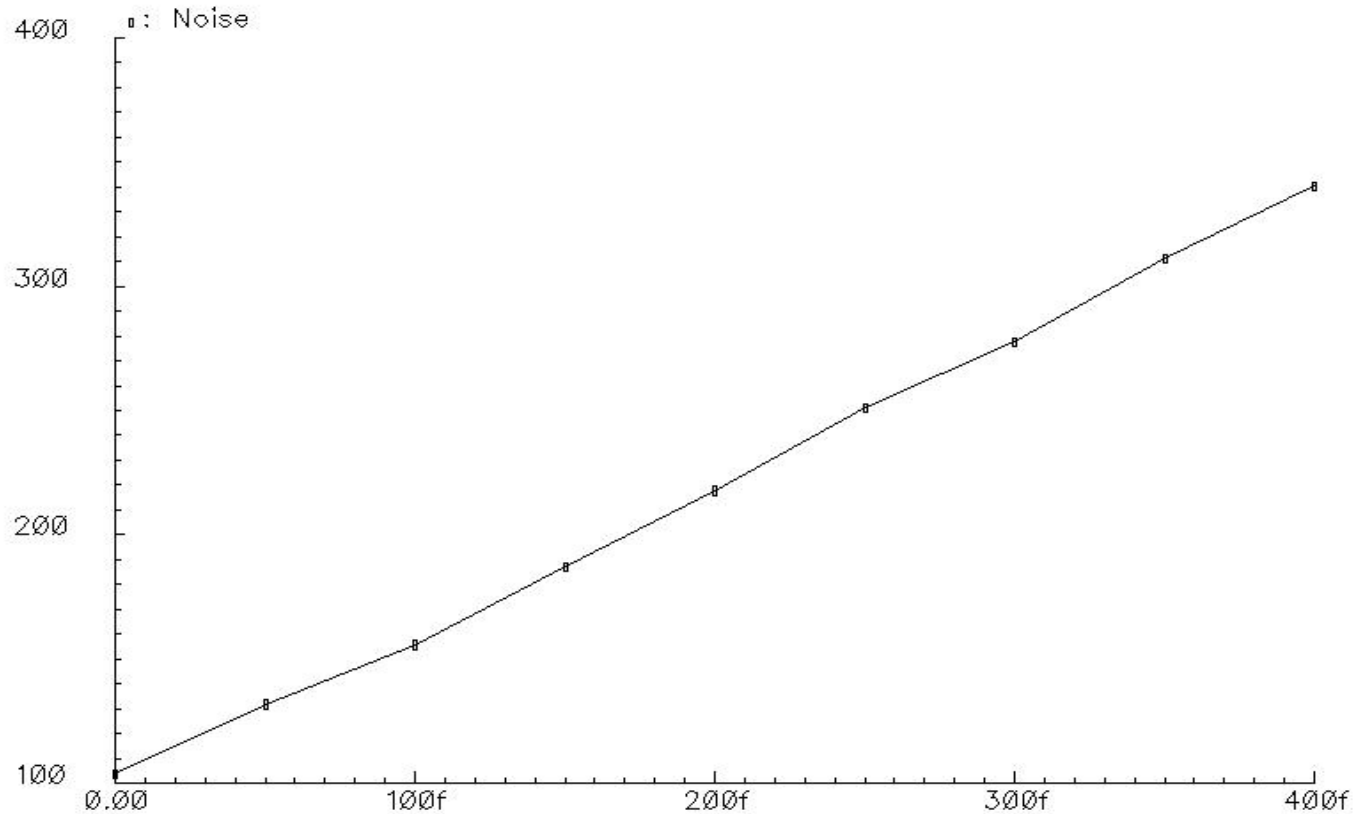
- The development will run for a few years: **state of the art** process.
- CMOS **0.13 μm** seems the most appropriate choice.
- Gain in density with respect to 0.25 μm , especially for digital parts:
 - Less **power consumption** for the same clock speeds.
 - Increased functionality at the pixel level.
 - Reduced **dead area** at the chip periphery (25% in the ATLAS chip).
- Some interesting features (lightly doped substrate, triple well NMOS transistor...)
- Cost is an issue (600 k\$ for an engineering run)

- Same circuit simulated in $0.25\ \mu\text{m}$ and in $0.13\ \mu\text{m}$.



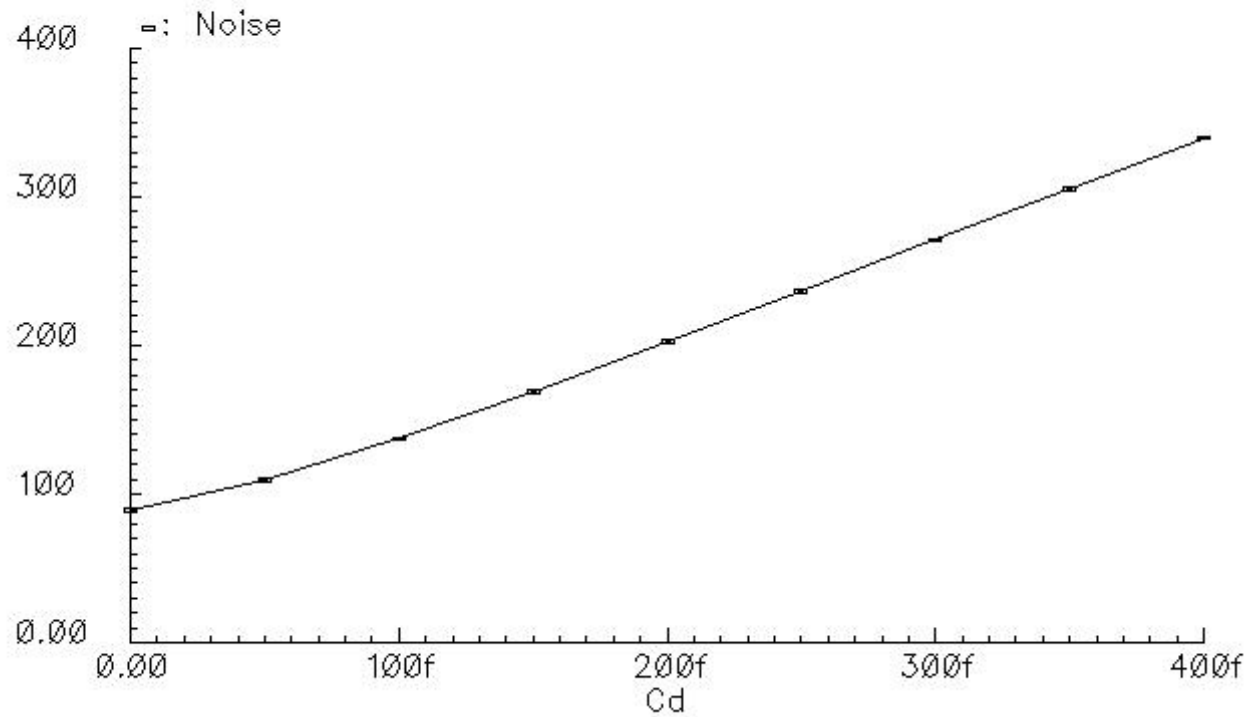
- Transistor length = $2 * L_{min}$.
- W/L kept constant.
- First simulation: circuit implemented in $0.25\ \mu\text{m}$ at $2.5\ \text{V}$ and circuit implemented in $0.13\ \mu\text{m}$ at $1.5\ \text{V}$. Same power.
- Second simulation: same power supply and current in both amplifiers.

Expressions



Noise slop: 64 electrons/100 fF @ 7ns peaking time

Expressions



Noise slop: 68 electrons/100 fF @ 6ns peaking time

- With the **same current** in the input transistor, both circuits have basically the **same performance**.
- At the current level allowed in a pixel, transistors will be in **weak inversion** in any deep submicron process.
- The higher **noise slope** in $0.13 \mu\text{m}$ is easily explained with the **faster peaking time**.
- The **faster peaking time** is explained with reduced **parasitic capacitance**.
- **Comparable analogue performance** should be achieved in **half the area**.
- Dynamic range is an issue with **1.5 V power supply**, but also the LHC pixel chip are operated with a **reduced power supply** to reduce power consumption.



A New Prototype $10\ \mu$ by $340\ \mu$ Pixel Cell in a $0.13\ \mu$ CMOS Process for Future HEP Applications

Abder Mekkaoui,
Jim Hoff, Ray Yarema

Fermilab, Batavia, IL

- Work presented at the Pixel05 workshop by the Fermilab group
- Pixel cell: $10\ \mu\text{m} \times 340\ \mu\text{m}$.
- Power consumption: $80\ \mu\text{W}/\text{pixel}$.
- General purpose R&D design with several test structures.

Pixel Cell Operating Conditions



Parameter	Value	Bias	Simulated	Measured
VDDA	1.5 V	VBP2	1.066 V	1.04 V
VDDD	1.5 V	VBN2	0.297	0.28
IDDA	12 mA	VBN1	0.374	0.364
IDDD	1 mA	VBBND	0.318	0.300

Power dissipation is around 80 uw/pixel cell.

The good correlation between simulated and measured bias voltages suggests that the models used for the pixel cells are good. (Also good noise correlation.)

Look at ENC and threshold characteristics for different columns.

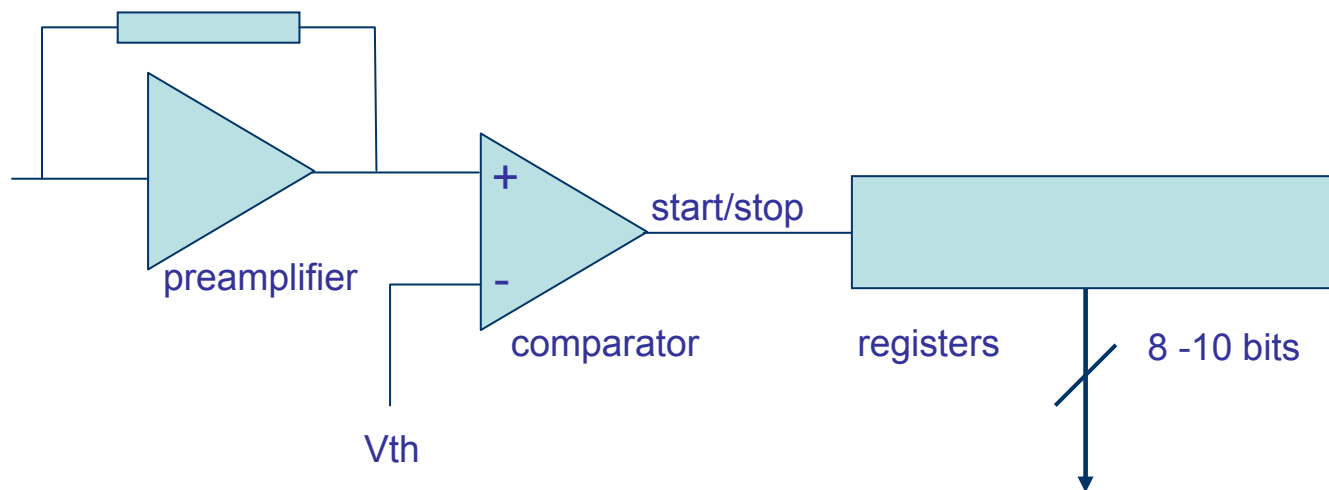
September 5, 2005

Pixel 2005, Bonn, Germany

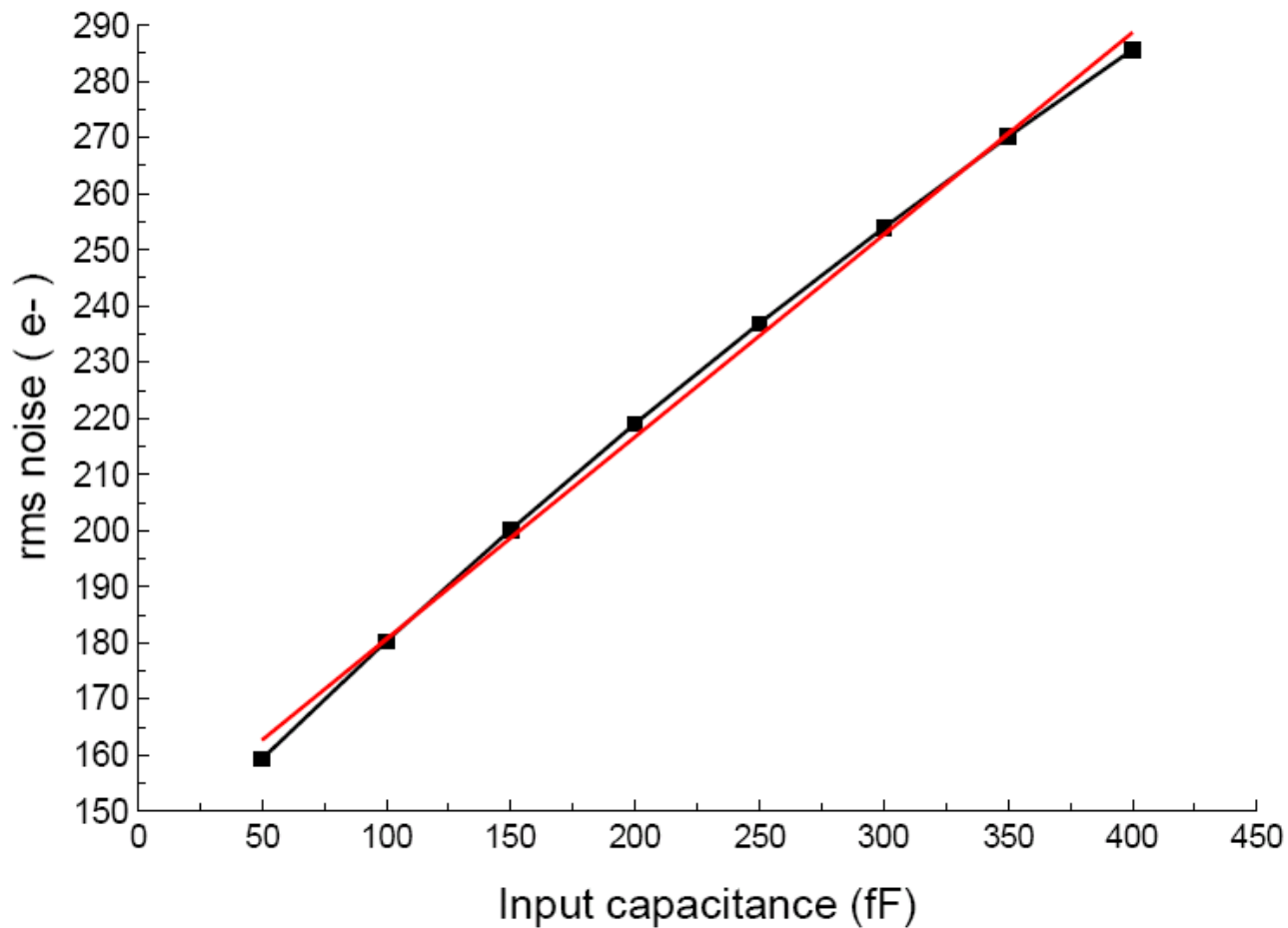
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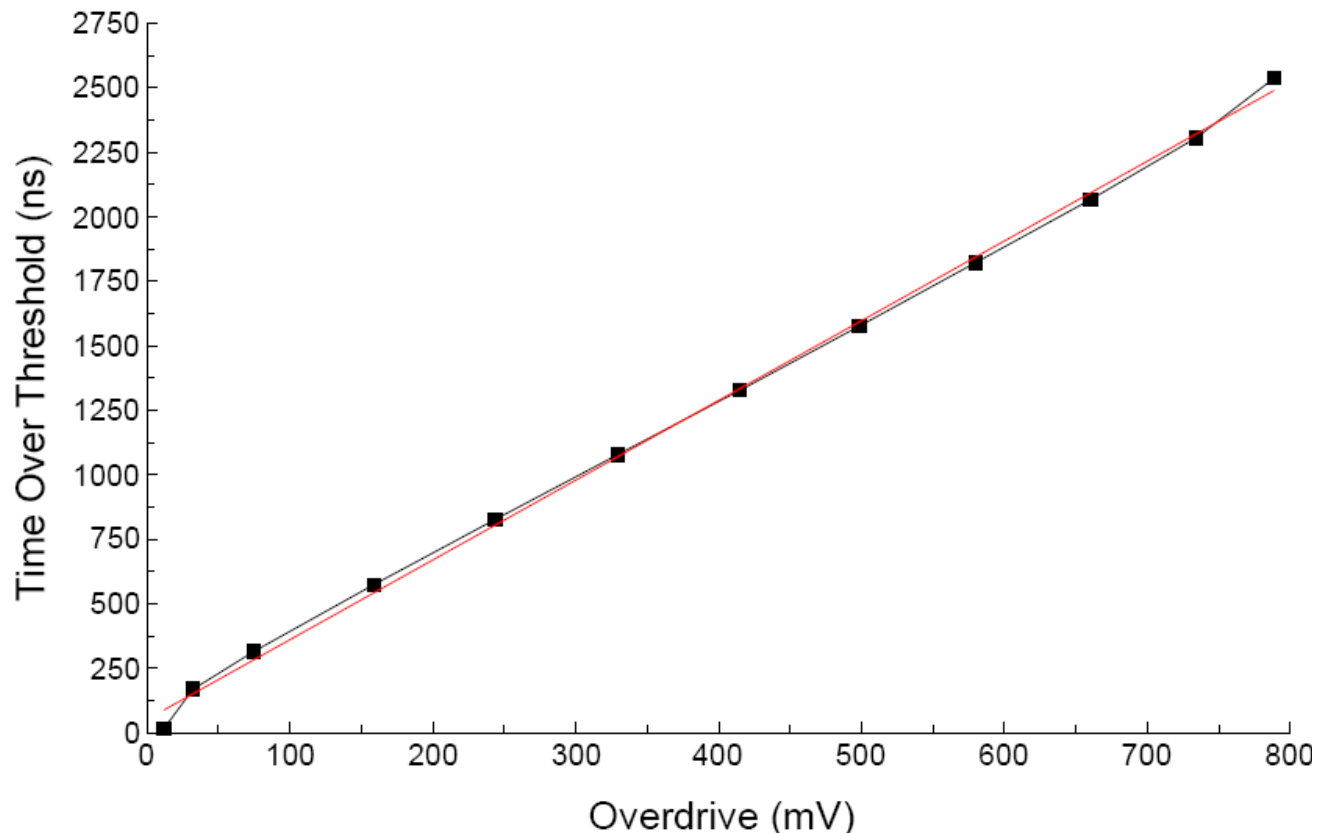
- The authors observed **good correlations** between simulations and results

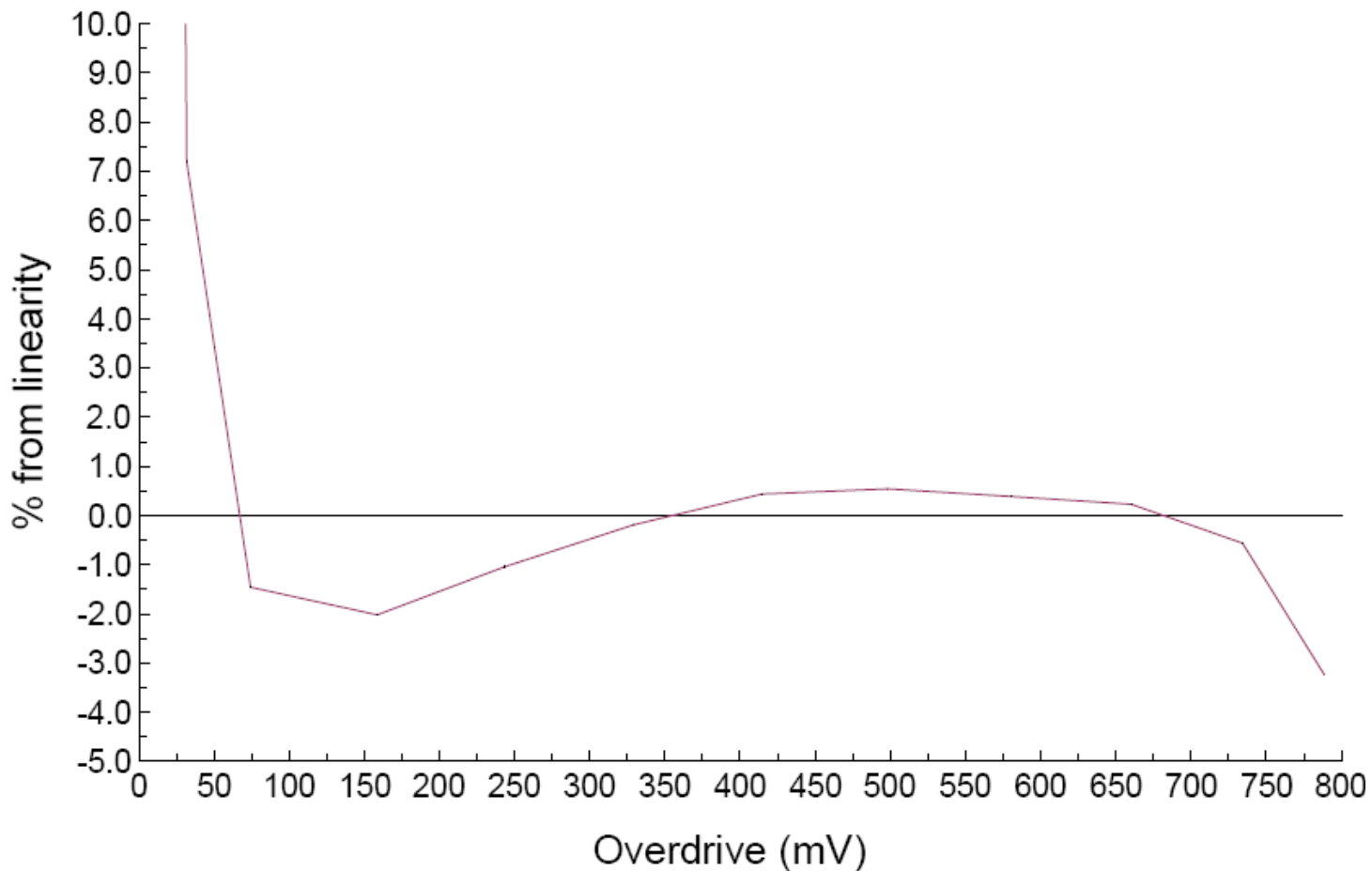
- Submission of first **building blocks** in 0.13 μm in December 2005.
- Submission of an **array of complete** pixel cells: December 2006.
- First **reduced scale** prototype: beginning of 2008.
 - Full functionality
 - Reduced number of pixel cells
- One **additional prototype** for bug fixing: end of 2008.
- **FPGA** based **prototype** of the control chip: 2006 – 2007.
- Prototype of the control chip: mid 2008.
- Engineering run: late 2009.
- More electronics is needed (optoelectronics components, detector control chip) but it may be re-used from other applications (semi-custom system).



- Few **pixel cells** with different device options.
- Digitization with **time over-threshold**.
- Some read-out logic.

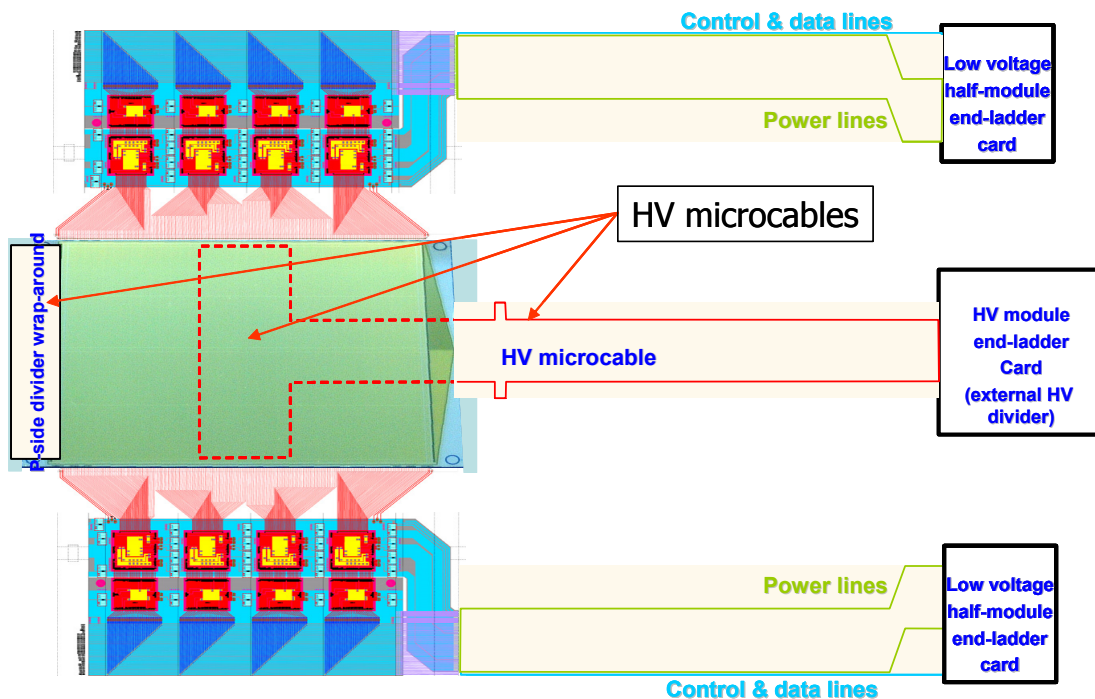






- Material **budget** is critical for the **MVD**.
- Hybrid pixels are **worse** in this respect than **MAPS** or **strips**.
- State of the art: ALICE pixel detectors (**200 μm** sensor and **150 μm** electronics).
- In principle, there is room for **further thinning**.
- In practice, the yield of **bump bonding** is the major concern.
- The issue needs to be addressed **before** the final approach is chosen.
- A dedicated effort is under discussion.

ALICE SDD system

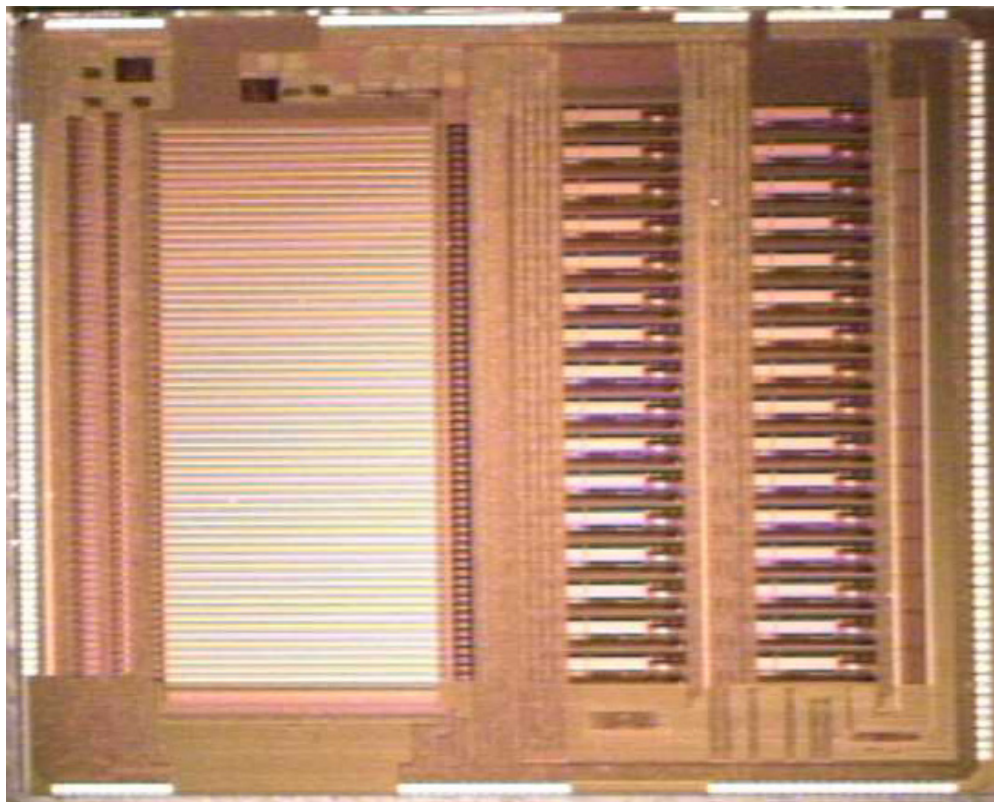


Custom for the experiment:

- Detector (INFN Trieste)
- FE electronics (INFN Torino)
- Data compression chip (INFN Bologna)

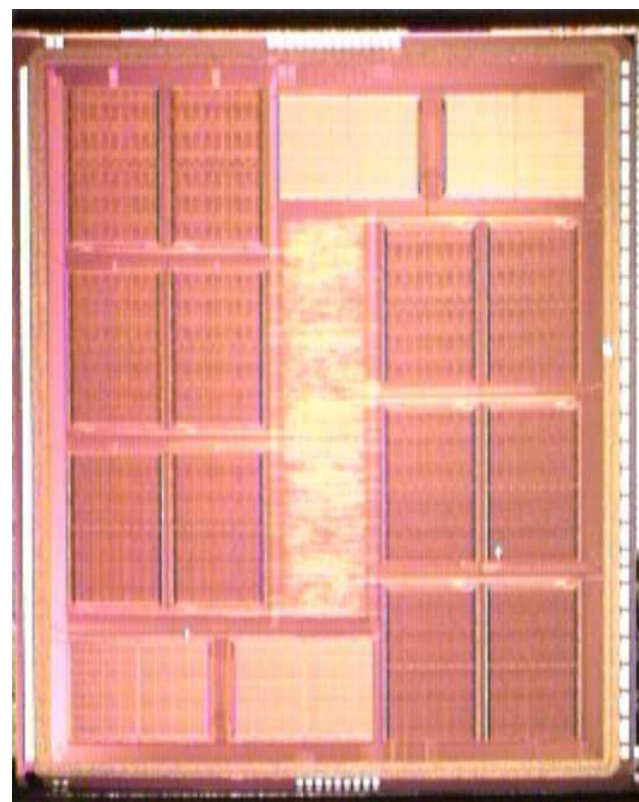
Re-used from other experiments (CMS)

- GOL (CERN)
- RX 40 (CERN)
- DCU (CERN)



Mixed mode front-end chip:

- 64 channels
- 32 10 bit SAR ADC
- 40 MHz clock



Digital front-end chip:

- Baseline correction
- Multi-event buffering
- 40 MHz clock

- The design of the MVD is still **evolving**.
- First steps towards the design of a **custom front-end** being done.
- CMOS 0.13 μm could provide **improvements** in several area.
- The major concern is the **cost**, that can be reduced:
 - By sharing the **same chips** among different applications.
 - By sharing the **same masks**.
- The design of a complex ASIC is a **lengthy process**, but there is some time ahead.
- However, there are other aspects equally important to achieve good **system performance** (mechanics, cabling, cooling).
- Several of those issues can be addressed without the **final electronics** (dummy chips, etc.).